# From Vertex Detectors to Inner Trackers with CMOS Pixel Sensors

#### Alejandro Pérez Pérez IPHC – CNRS Strasbourg







WISCS WITH INTEGRATED CMOS SENSORS AND ELECTRON MACHINES

# **Outline**

- Introduction to CMOS Pixel Sensors (CPS)
- CPS adapted to an inner tracker: ALICE-ITS Upgrade
- Next R&D challenges
- Summary

# **Introduction to CPS**

# **CPS: Development motivation**

- CPS triggered by the need of very granular and low material budget sensors
- CPS applications exhibit milder running conditions than at pp/LHC
  - Relaxed readout (r.o.) speed & rad. tolerance



- Application domain widens continuously (existing/foreseen/potential)
  - Heavy-ion collisions
    - STAR-PXL, ALICE-ITS, CBM-MVD, NA61...
  - e<sup>+</sup>e<sup>-</sup> collisions
    - > BES-III, ILC, Belle II (BEAST II)
  - Non-collider experiments
    - FIRST, NA63, Mu2e, PANDA, ...
  - High-precision beam-telescopes (adapted to medium/low energy e<sup>+</sup> beams)
    - Few μm resolution @ DUT achievable with EUDET-BT (DESY), BTF-BT (Frascati)

# **CPS: Main features**

#### The basic working principle

- Secondary charges generated in epi-layer by ionization
  - Signal proportional to epi-thickness
- Charges transport driven by 3 potentials
  - P-well/coll. node/P++ (usually GND/few volts/GND)
- Epi-layer not fully depleted:  $d_{dep} \sim 0.3 \sqrt{\rho_{sub} \times U_{bias}}$

 $\Rightarrow$  transport is mix of thermal diffusion & drift

#### Prominent features

- Signal processing integrated on sensor substrate  $\Rightarrow$  downstream electronics & syst. integration
- High granularity  $\Rightarrow$  excellent spatial resolution (O( $\mu$ m))
- Signal generated in thin (10-40 $\mu$ m) epi-layer  $\Rightarrow$  usual thinning up to 50  $\mu$ m total thickness
- Standard fabrication process ⇒ low cost & easy prototyping, many vendors, …

#### CPS technology potential

- Mainly driven by commercial applications ⇒ Not fully optimized for particle detection
- R&D largely consists in exploiting as much as possible the potential of the accessible industrial processes



# **CPS @ PICSEL - IPHC: A long term R&D**

#### Ultimate objective: ILC, with staged performances

...

On-going R&D

HR-CMOS for X-rays (2018)





ILC >2020 International Linear Collider



EUDET (R&D for ILC, EU project) STAR (Heavy Ion physics) CBM (Heavy Ion physics) ILC (Particle physics) HadronPhysics2 (generic R&D, EU project) AIDA (generic R&D, EU project) FIRST (Hadron therapy) ALICE/LHC (Heavy Ion physics) EIC (Hadron physics) CLIC (Particle physics) BESIII (Particle physics)

<u>CBM >2018</u>

Compressed Baryonic Matter

RICH mirror

RICH rediat

Dipole magne

Silicon tracker

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STAR 201

Solenoidal Tracker at RH

**ALICE 2018** 

A Larae Ion Collider Experime

# **CPS State-of-the-Art in operation: STAR-PXL sensor**

#### ULTIMATE main characteristics

- CMOS sensor (0.35  $\mu$ m AMS twin-well) high- $\rho$  epi-layer 15 $\mu$ m
- Sensor thinned to 50  $\mu$ m (total thickness  $\Rightarrow$  0.05% X<sub>0</sub>)
- || column (rolling shutter) r.o. with in-pixel CDS & amplification
- End-of-column discriminator (1-bit) followed by Ø-suppression
- 960 x 928 (columns x rows) pixels of 20.7 μm pitch ⇒ 19.9 x 19.2 mm<sup>2</sup> sensitive area
- $t_{r_0} \leq 200 \ \mu s \ (\sim 5 \times 10^3 \ frames/s) \Rightarrow$  suited for > 10<sup>6</sup> part./cm<sup>2</sup>/s
- 2 outputs @ 160 MHz
- Operation @ T ~30 °C & W  $\leq$  150 mW/cm<sup>2</sup>

# ULTIMATE Performances

- Noise ≤ 15 e<sup>-</sup> ENC @ 30-35 °C
- $\varepsilon_{det} \gtrsim 99.9\%$ ,  $\sigma_{sp} \gtrsim 3.5 \mu m$ , Fake rate  $\leq 10^{-5}$
- Rad. hardness validated @ 30 °C (150 kRad ⊕ 3×10<sup>12</sup> n<sub>eq</sub>/cm<sup>2</sup>)

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MIMOSA 28 - epi 15 um

# **CPS State-of-the-Art in operation: STAR-PXL detector**

#### STAR-PXL @ RHIC: 1<sup>st</sup> CPS @ a collider experiment !





#### **STAR-PXL HALF-BARREL**

- 2 layers @ r = 2.8,8 cm
- 20 ladders (10 sensors) (0.37% X<sub>0</sub>)

 $\Rightarrow$  180M pixels

• Air flow cooling: T < 35°C



# **CPS State-of-the-Art in operation: STAR-PXL detector**

### STAR-PXL @ RHIC: 1<sup>st</sup> CPS @ a collider experiment !



# CPS performances: Spatial Resolution ( $\sigma_{sn}$ )

- Several parameters govern σ<sub>sp</sub>
  - Pixel pitch
  - Epi-layer: thickness & ρ
  - Sensing node: geometry & electrical properties
  - Signal-encoding resolution: Nb of bits
  - σ<sub>sp</sub> function of:
     pitch ⊕ SNR ⊕ charge-sharing ⊕ ADCu ⊕ ...
- Pixel-pitch impact (analogue output)
  - Pitch = 10 (40)  $\mu$ m  $\Rightarrow \sigma_{so} \sim 1 \mu$ m ( $\leq 3 \mu$ m)
  - Nearly linear improvement in σ<sub>sp</sub> vs pixel pitch
- Signal-encoding impact (digital output)
  - $\sigma_{sp}^{digi} = pitch/(12)^{1/2}$ 
    - $\Rightarrow$  e.g.  $\sigma^{\text{digi}}_{\text{sp}}$  ~ 5.7  $\mu m$  for 20  $\mu m$  pitch
  - Significant improvement in σ<sub>sp</sub> by increasing signal encoding resolution



#### pitch (microns)

Nb of bits123-41Datameasuredreprocessedmeasured $\sigma_{sp}$  $\lesssim 1.5 \mu m$  $\lesssim 2 \mu m$  $\lesssim 3.5 \mu m$ 

# **CPS performances: r.o. speed & rad. hardness**







- 15 years of experience of PICSEL group in developing CPS
- Strong collaboration with ADMOS group at Frankfurt

#### r.o. speed evolution

Two orders of magnitude
 improvement in 15 years of research

#### Radiation tolerance

- Significant improvement with time
- Sensor validation up to 10 MRad  $\otimes$   $10^{14}n_{eq}/cm^{2}$
- Adequacy to ALICE-ITS and CBM applications

# Development of CPS adapted to Vertex & Tracker detector

# Next challenge: ALICE-ITS upgrade

# ALICE goals

- Study quark gluon plasma in heavy-ion collisions
- High precision measurements @ low-p<sub>T</sub>

# Upgraded ITS entirely based on CPS

- **Present detector:** 2xHPD/2xDrift-Si/2xSi-strips
- Future detector: 7-layers with CPS (25-30k chips)
  - $\Rightarrow$  1<sup>st</sup> large tracker (~ 10 m<sup>2</sup>) using CPS
- ITS-TDR approved on March 2014 (Pub. In J.Phys. G41 (2014) 087002)

# New ALICE-ITS requirements

	$\sigma_{sp}$	$t_{r.o.}$	Dose	Fluency	$T_{op}$	Power	Active area
STAR-PXL	$<$ 4 $\mu m$	$<$ 200 $\mu s$	150 kRad	$3{\cdot}10^{12}~{ m n}_{eq}/{ m cm}^2$	30-35°C	160 mW/cm $^2$	0.15 m <sup>2</sup>
ITS-in	$\lesssim$ 5 $\mu m$	$\lesssim$ 30 $\mu s$	2.7 MRad	1.7 $\cdot$ 10 <sup>13</sup> n <sub>eq</sub> /cm <sup>2</sup>	30°C	$<$ 300 mW/cm $^2$	$0.17 \text{ m}^2$
ITS-out	$\lesssim$ 10 $\mu m$	$\lesssim$ 30 $\mu s$	100 kRad	$1{\cdot}10^{12}~\mathrm{n}_{eq}/\mathrm{cm}^2$	30°C	$<$ 100 mW/cm $^2$	$\sim$ 10 m $^2$

 Different requirements on inner & outer layers calls for different chips designs!

#### $\Rightarrow$ 0.35 $\mu m$ CMOS process (STAR-PXL) marginally suited to this r.o. speed & rad. hardness







# CMOS Process Transition: STAR-PXL $\rightarrow$ ALICE-ITS



- Use of PMOS in pixel array not allowed
   ⇒ parasitic q-collection of additional N-well
- Limits choice of readout architecture strategy
- Already demonstrated excellent performances
  - **STAR-PXL:** Mi-28 (AMS 0.35  $\mu$ m process)  $\Rightarrow \varepsilon_{det} > 99.5\%, \sigma_{sp} < 4\mu m$
  - <sup>2</sup> 1<sup>st</sup> CPS detector @ collider experiment







- N-well of PMOS transistors shielded by deep P-well  $\Rightarrow$  both types of transistors can be used
- Widens choice of readout architecture strategies
  - New ALICE-ITS: 2 sensors R&D in || using TowerJazz CIS 0.18 um process (quadru. well)
    - → Synchronous Readout R&D: proven architecture ⇒ safety
    - Asynchronous Readout R&D: challenging



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# **ALICE-ITS: Boundaries of the CPS Development**

## New fabrication process (TowerJazz CIS 0.18 μm)

- Expected to be ration tolerant enough
- Expected to allow for fast enough readout
- Larger reticule: ~ 25 x 32 mm<sup>2</sup>

#### Drawback of smaller feature size

• 1.8 V operative voltage (instead of 3.3 V)

 $\Rightarrow$  reduced dynamics in signal processing circuit and epi-layer depletion voltage

• Increase risk of Random Telegraph Signal (RTS) noise

#### Requirements of the larger surface to cover

- Good fabrication yield ⇒ sensor design robustness
- Mitigate noisy pixels
- Sensor operation stable along 1.5 m ladder (voltage drop)
- Material budget
  - Minimize power consumption
  - > Minimal connexions to the outside  $\Rightarrow$  sensor periphery (slow-control, steering, ...)

STAR-PXL	ALICE-ITS	added-value
<b>0.35</b> $\mu m$	0.18 $\mu m$	speed, TID, power
4 ML	6 ML	speed. power
twin-well	quadruple-well	speed, power
EPI 14/20 $\mu m$	EPI 18/40 $\mu m$	SNR
EPI $\gtrsim$ 0.4 k $\Omega \cdot cm$	EPI $\sim$ 1 - 8 k $\Omega \cdot cm$	SNR, NITD



# **ALICE-ITS: Readout chain components**



#### Typical readout components

- **AMP:** in-pixel low noise pre-amplifier
- Filter: in-pixel filter
- **ADC** (1-bit = discriminator): may be implemented at end-of-column or pixel level
- Zero suppression (SUZE): only hit pixel info is retained and transferred
  - Implemented at sensor periphery (usual) or inside pixel array
- Data transmission: O(Gbps) link implemented at sensor periphery

#### r.o. alternatives

- Rolling shutter (synchronous): || column r.o. reading N-lines at the time (usually N = 1-2)
- data-driven (asynchronous): only hit pixels are output upon request (priority encoding)
- Rolling shutter: best approach for twin-well process
  - Trade-off between performance, design complexity, pixel dimensions, power, ...
     e.g.: Mimosa-26 (EUDET-BT), Mimosa-28 (STAR-PXL)

# **ALICE-ITS: Two Architectures for the pixel chip**



# Exploring the new technology

# **Technology Exploration & Sensor Performances**

Goal: understand the detection performances in terms of external parameters
 ⇒ Optimization for ALICE-ITS (and evaluate adequacy for other applications)

## External parameters

- Diode and spacing (footprint) size/geometry
- Pixel size/geometry: square vs elongated
  - Elongated pixels in row direction (less rows)
    - $\Rightarrow$  Lower t<sub>ro</sub> of rolling shutter
- Diode layout of elongated pixels
  - → Staggering  $\Rightarrow$  lower diode inter-distance
- Epi-layer: thickness and resistivity (profile)

# Performances in terms of

- Noise
- CCE, SNR @ seed pixel
- Hit pixel multiplicity  $\Rightarrow$  data transmission
- $\epsilon_{det}^{}, \sigma_{sp}^{}$  & Fake-rate
- Rad. Tolerance



# **Exploratory chips: MIMOSA-32ter & MIMOSA-34**

- TowerJazz 0.18um technology validation & performances optimization
- MIMOSA-32ter
  - Analog-output: source follower or feedback-loop (t<sub>int</sub>~34 or 12 μs)
  - Sub-matrices of 16x64 pixels with different sizes (20x20,33,40,80 μm<sup>2</sup>), diodes geometries (octagonal vs square) and some with deep P-well
  - Epi-layer: 18  $\mu$ m HR ( $\rho$  = 1 k $\Omega$  cm)
- MIMOSA-34
  - Analog-output: source follower (t<sub>int</sub> ~ 32µs)
  - 30 sub-matrices with 16x64 staggered pixels
    - Dimensions: 22 or 33 x(27, 30, 33, 44, 66) μm<sup>2</sup>
    - > **Diode/footprint:** 1+1, 2, 5, 5+5, 8, 11, 15  $\mu$ m<sup>2</sup> / 11,15  $\mu$ m<sup>2</sup>
  - **Epi-layer:** 18, 20, 30 μm HR ( $\rho$  = 1 6 kΩ cm)



#### Test purposes

- Validate new technology: epi-layer characteristics, deep P-well and Rad. tolerance
- Study: sensing node charge collection, elongated pixels performances

# **MIMOSA-32ter: performances**

# CERN-SPS BT Set-up

- Beam: 60-120 GeV/c π<sup>+</sup>
- $T_{cooling} = 15, 20 \& 30^{\circ}C$

#### Main results

- 20x20  $\mu$ m<sup>2</sup> pixel (performances vs rad. dose @ 30°C)
  - → Small noise increase:  $21 \rightarrow 26 e^{-} ENC$
  - > SNR<sub>seed</sub> reduction:  $26-28 \rightarrow 19 (30\%)$
  - >  $\epsilon_{det}$  > 99% for 1MRad  $\oplus$  10<sup>13</sup>n<sub>ed</sub>/cm<sup>2</sup>
  - $\sim \sigma_{sp} \sim 3.2 \, \mu m$
- 20x40 μm<sup>2</sup> pixel (@ 20°C)
  - >  $\epsilon_{det}$  > 99% for 1MRad  $\oplus$  10<sup>13</sup>n<sub>eo</sub>/cm<sup>2</sup>
  - > σ<sub>sp</sub> ~ 5.0 μm

#### Technology validation

- HR epi-layer 🗸
- deep P-well (no parasitic charge coll.)
- Radiation tolerance

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Noise distribution

# **MIMOSA-34: performances vs diode & pixels sizes**

# DESY BT Set-up (August 2013):

- 2BT: 8xSi-strips & 6xMIMOSA-26 (120 μm thick)
- ~4.4 GeV/c e<sup>-</sup> beam
- MIMOSA-34: Various pixels & diode dimensions
  - Pixel (22x27,30,33,44,66) & diode (8,11,15) sizes (μm<sup>2</sup>)
  - Excellent SNR<sub>seed</sub> for various considered pixels  $\Rightarrow$  e.g. MPV > 40 for 22x66  $\mu$ m<sup>2</sup> pixel  $\Rightarrow \epsilon_{det} \sim 100\%$
  - **33x66 μm<sup>2</sup> pixel:** Not tested in BT but with β-source
    - > Excellent MPV (> 50)  $\Rightarrow$  expects  $\varepsilon_{det} \sim 100\%$  &  $\sigma_{sp} \sim 10\mu m$
    - Pixel size adapted for ALICE-ITS outer layers (MISTRAL-O)

<b>Process</b> $\triangleright$ 0.35 $\mu m$		0.18 $\mu m$				
Pixel Dim. $[\mu m^2]$	20.7×20.7	20×20	22×33	20×40	22×66	33×66
$\sigma^{bin}_{sp}[\mu m]$	$3.7\pm0.1$	$3.2\pm0.1$	$\sim 5$	$5.4 \pm 0.1$	$\sim$ 7	$\sim$ 10 $\mu m$ ?

- Variations showed acceptable degradation of performances for nominal TID + NIEL @ ALICE-ITS
- Next-step: optimization with pre-ampli scheme

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Seed pixel SNR vs pixel size

# **Going MISTRAL-O**

# Main features of the Sensors Studied on Beam

# Full Scale Building Block (FSBB) sensor Complete (fast) chain of double-row r.o. and 2D sparcification (SUZE): t<sub>r.o.</sub> = 40 μs Sensitive area (~1 cm<sup>2</sup>) ≈ area of final building bock Similar Nb of pixels (~170k) than complete final chip (160k) Fabricated with 18 μm thick high-ρ epi-layer BUT: pixels are small (22x32.5 μm<sup>2</sup> staggered layout) & sparsification circuitry is oversized (power!)

 Tested @ DESY (~4 GeV/c e<sup>-</sup>) in Jun. 2015, and CERN-SPS (~ 120 GeV/c π<sup>-</sup>) in Oct. 2015

# Large-pixel prototype (MIMOSA-22THRb)

- Two slightly different large pixels
  - >  $36x62.5 \ \mu\text{m}^2$  and  $39x50.8 \ \mu\text{m}^2$  (staggered layout)
- Pads over pixel array (3ML used for in-pixel circuitry)
- Double-row r.o. with no-sparsification ( $t_{r.o.} \sim 5 \mu s$ )
- Fabricated with 18  $\mu$ m thick high- $\rho$  epi-layer
- **BUT:** only  $\leq$  10 mm<sup>2</sup>, 4k pixels & no sparsification
- Tested in Frascati (450 MeV/c e<sup>-</sup>) in Mar. & May 2015





# Main goals of MIMOSA-22THRb & FSBB-M0 Prototyping

Parametres investigated	MIMOSA-22THRb7/6	FSBB-M0bis
Sensing node geometry	Х	Х
Epitaxial layer parametres	Х	Х
In-pixel signal processing	X	x
on 3 ML (Pre-Amp, clamping)	X	-
Pads over pixels	Х	-
Large pixel detection efficiency	X	-
at 30 $^\circ$ C (incl. after OB radiation load)	Х	-
Large pixel single point resolution	Х	-
Complete signal sensing & processing chain	_	Х
Fake rate (160,000 pixels)	x	Х
Impact of voltage drop	_	Х
Cluster encoding data size	X	x

# FSBB BT @ CERN-SPS in Oct. 2015

#### Experimental set-up

- 3 pairs of FSBB planes on T4/H6 (120 GeV/c  $\pi^-$ )
- Particle flux: trigger rate ~4, 25 & 100 kHz/cm<sup>2</sup>
- All measurements performed at T<sub>coolant</sub> = 30 °C



#### Measurements as a function of discriminator threshold

- Detection efficiency vs fake rate (noisy pixel)
- Spatial resolution associated with binary encoding of 22x32.5 μm<sup>2</sup> pixels
- Radiation tolerance @  $T_{coolant}$  = 30 °C: up to 1.6 MRad  $\oplus$  1.0×10<sup>13</sup>  $n_{eq}$ /cm<sup>2</sup>
- Studies of the impact of operation parameters on sensor performances
  - e.g. input voltage (VDD), pixel current, ...
- Study of the impact of noisy pixel masking on efficiency and spatial resolution

# Main FSBB-M0 detection performances (1/3)



#### Detection performances stability

- Same results obtained @ DESY (4.5 GeV/c  $e^{-}$ ) and CERN-SPS (120 GeV/c  $\pi^{-}$ )
- Same results for different particles rates: 1 25 hits/frame
- Robust performances in terms of operation parameters

# Main FSBB-M0 detection performances (2/3)

#### Spatial resolution vs cluster pixel size



# Main FSBB-M0 detection performances (2/3)

#### Spatial resolution vs cluster pixel size



# Main FSBB-M0 detection performances (3/3)

Study of rad. tolerance @ T ≥ 30 °C: loads relevant to ALICE-ITS inner layers

• Load: 1.6 MRad ⊕ 10<sup>13</sup>n<sub>e</sub>/cm<sup>2</sup>



#### Diode/Footprint: 9/13.3 µm<sup>2</sup>

# Main FSBB-M0 detection performances (3/3)

Study of rad. tolerance @ T ≥ 30 °C: loads relevant to ALICE-ITS inner layers

• Load: 1.6 MRad  $\oplus$  10<sup>13</sup>n<sub>ed</sub>/cm<sup>2</sup>



# Main FSBB-M0 detection performances (3/3)

Study of rad. tolerance @ T ≥ 30 °C: loads relevant to ALICE-ITS inner layers

• Load: 1.6 MRad  $\oplus$  10<sup>13</sup>n<sub>ed</sub>/cm<sup>2</sup>



# MIMOSA-22THRb BT @ Frascati in May 2015

#### Experimental set-up

- Beam: 450 MeV/c e<sup>-</sup>
- Telescope: 2xMi28 (digital output) and 4xMi18 (analog-output) sensors thinned to 50 μm
- **Trigger:** beam injection signal ⇒ synchronisation due to small spill length (few ns)



- Measurements as a function of discriminator threshold
  - Detection efficiency vs fake rate (noisy pixel)
  - Spatial resolution associated with binary encoding of  $36x65.2 \ \mu m^2 \& 39x50.8 \ \mu m^2$  pixels
  - Radiation tolerance @ T<sub>coolant</sub> = 30 °C: up to 150 kRad ⊕ 1.5×10<sup>12</sup> n<sub>eq</sub>/cm<sup>2</sup>

# Main MIMOSA-22THRb detection performances (1/2)



#### Validation of large pixel design for the outer layers of the ALICE-ITS!

# **Final Sensor: MISTRAL-O**

Combination of 4 FSBB-M0 with MIMOSA-22THRb7 pixels

#### Main characteristics

- Chip dimensions: 15 x 30 mm<sup>2</sup>
- Sensitive area: 13.5 x 29.95 mm<sup>2</sup>
  - 1.5 mm wide side band (insensitive) (evolving towards 1 mm)
- 832 columns of 208 (160k) pixels
- Pixel dimensions: 36 x 65  $\mu$ m<sup>2</sup>
- In-pixel Pre-Amp & clamping (fringe capa)
- End-of-column signal discriminator
- Discriminator's output 2D sparsification (SUZE)
- Fully programmable control circuitry
- Pads over pixel array

# Typical performances (based on FSBB-M0 & MIMOSA-22THRb tests)

- $t_{r_0} \sim 20 \ \mu s; \sigma_{s_0} \sim 10 \ \mu m;$  Power consumption  $\leq 80 \ mW/cm^2$
- Rad. Hardness > 150 kRad ⊕ 1.5x10<sup>12</sup> n<sub>g</sub>/cm<sup>2</sup> @ T ≥ 30 °C



# **Forthcoming Challenges**
### Forthcoming Challenges: R&D @ IPHC



## Micro Vertex Detector (MDV) of CBM @ SIS100

### Goals

- Study of super-dense nuclear matter with relativistic ion-collisions
- Study open charm from 30 GeV p-Au (10 MHz)
- Low-momentum tracker for 1-12 GeV Au-Au (30-100 kHz)
- Beam on target > 2021
- MVD sensor requirements



Sensor properties	MISTRAL - O	MIMOSIS-100 (preliminary)
Active surface	13.5 x 29.95 mm <sup>2</sup>	~ 10 x 30 mm²
Pixels	832 colls x 208 pixels	~ 1500 colls x 300 pixels
Pixel pitch	36 x 65 µm² 🛛 🗕	
Integration time	20.8 µs	30 µs
Data rate	320 Mbps	> 6x 320 Mbps
Rad tol. (non-io)	>10 <sup>12</sup> n <sub>eq</sub> /cm²	>3 x 10 <sup>13</sup> n <sub>eq</sub> /cm <sup>2</sup>
Rad tol (io)	> 100 kRad	> 3 MRad
Operation Temperature	+30°C	-20°C in vacuum

### In reach with lightly modified APIDE (FSBB?)

## **Towards ILC vertex detector**



## **Technology Perspectives for Performance Improvements**

### • HV/HR-CMOS sensors: $d_{dep} \sim 0.3 \sqrt{\rho_{sub} \times U_{bias}}$

- Extend sensitive volume & improved q-collection
  - $\Rightarrow$  Faster signal & stronger rad. tolerance
- Not bound to CMOS processes using epi-layers
  - Easier access to VDSM (< 100 nm) process</li>
  - Higher in-pixel µ-circuitry density
- Unanswered questions
  - > Minimal pixel dimensions  $(\sigma_{sp})$  ?
  - > Uniformity over large sensitive area & production yield?

### 2-tiers chips

- Signal sensing (front-end) & processing (r.o.) parts distributed over two interconnected tiers (AC coupling)
- Smart sensor  $\Rightarrow$  1 r.o. pixel addressing N pixel-front-ends
  - $\Rightarrow$  Reduce density of interconnections
- Can combine 2 diff. CMOS processes: front-end/r.o.
- Benefits: small pixels ⇒ resolution, speed, datacompression and robustness
- Challenges: interconnection technology (reliability & cost)

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van Peric: CPIX14, Bonn, 2014



### Summary

- Substantial experience has been collected with running STAR-PXL proving added value of CPS to physics
  - Demonstrated that CPS can provide spatial resolution and material budget required for numerous applications
- CPS are suited for vertex detectors (<< 1 m<sup>2</sup>) and have attractive features for tracking devices (>> 1 m<sup>2</sup>)
- Forthcoming Challenges
  - CPS for inner trackers: ALICE-ITS  $\Rightarrow$  large area (10 m<sup>2</sup>) to cover with 20-30k sensors
  - Improve rad. tolerance: CBM experiment @ FAIR/GSI  $\Rightarrow \ge 10^{14} \text{ n}_{sc}/\text{cm}^2$
  - Improve readout speed: ILC vertex detector  $\Rightarrow \leq 1 \ \mu s$
- Perspectives for technological advances
  - HV/HR-CMOS sensors: improvement on charge collection
    - $\Rightarrow$  faster signal and stronger rad. tolerance
  - 2-tier sensors: combine of 2 CMOS processes for sensing & r.o. parts
     ⇒ more in-pixel intelligence



## **ALPIDE (ALice Plxel DEtector): readout architecture**

#### Concept similar to hybrid pixel readout architecture

TowerJazz CIS quadrupole well process: both N & P MOS can be used

#### Continuously power active in each pixel

- Low power consumption analogue front-end (< 50nW/pixel) based on single stage amplifier with shaping
  - High gain ~100
  - Shaping time few μs
- In-pixel discriminator
- Binary output stored into multi-event buffer awaiting for external readout
- Only zero-suppressed data transferred to periphery ⇒ priority encoder readout





## **ALPIDE: performances assessment**

### APIDE-1 beam test @ DESY (5-7 pions)

- Final sensor dimensions: 15x30 mm<sup>2</sup>
- ~0.5M pixels of 28x28 μm<sup>2</sup>
- 4 different sensing node geometries
- Possibility of reverse biasing the substrate
   ⇒ default is -3 V (better epi-layer depletion)
- Possibility to mask pixels (fake-rate mitigation)
   ⇒ default is O(10<sup>-3</sup>) pixels

#### Performances

- $\varepsilon_{det} > 99\%$ ,  $\sigma_{sp} < 5\mu m$ , fake-rate < 10<sup>-5</sup>
- Slight deterioration after irradiation







# **Exploring full sensor chain: Prototypes fabricated**



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# **The Testing Probes**

### Laboratory tests

- Noise characterization and fake rate
- <sup>55</sup>Fe X-ray source
  - ~6keV line
  - Gain, CCE and CNR
- ${}^{90}$ Sr  $\beta^{-}$  source (Q = 2.28 MeV)
  - $\, {\scriptstyle \succ \,} \,$  SNR,  $\boldsymbol{\epsilon}_{_{det}}$  and cluster multiplicity

- Test-beam (TB) facilities
  - SPS: ~100 GeV/c π<sup>±</sup>
  - DESY: ~5 GeV/c e<sup>-</sup>
  - Frascati: ~500 MeV/c e<sup>−</sup>
  - SNR,  $\epsilon_{det}$ , cluster multiplicity and  $\sigma_{sp}$



# **MISTRAL-O: Synchronous readout**

#### Design addresses 3 issues

- Increasing S/N at pixel-level
  - Sensing node optimization
- ADC @
  - ≻ end-of-column ⇒ MISTRAL
  - → pixel  $\Rightarrow$  **ASTRAL**



Window of 4x5 pixels

- SUZE at chip periphery
  - 2D sparsification algorithm with 4x5 pixels window (evolution from 1D sparsification on ULTIMATE chip)



#### Power vs Speed

- **Power:** only the selected rows (N=1,2,3 ...) to be readout
- Speed: N rows of pixels are readout in ||
  - > Integration-time ( $t_{int}$ ) = frame readout time  $\Rightarrow t_{int}$

$$\int_{tt} = \frac{(Row \ readout \ time) \times (No. \ of \ Rows)}{N}$$

## **R&D of CMOS pixel sensors**



ALICE-ITS =NEW DRIVING APPLICATION OF CPS based on a better suited (180 nm) CMOS process (TDR approved by LHCC in March '14)

- ✤ 1<sup>st</sup> real scale sensor prototype adapted to 10 m<sup>2</sup> fabricated
  - → 1st test results validate achitecture in 180 nm technology
  - → 2-4 times faster read-out w.r.t. 0.35 µm technology, with up to 60 % power reduction



### AIDA Telescope

- Big surface and thin reference planes with high spatial resolution
- Sensing area = 4x3.8cm2
- Additional plane with high temporal

resolution

 $\Rightarrow$  time stamping



## Sensor integration in Ultra Light Devices

### Double sided ladders expected benefits

- Alignment & tracking (pointing)
- Beam background rejection ?
- Material budget, 1 mechanical support
- Redundancy (efficiency)
- Each layer optimized
  - read-out speed vs resolution
- PLUME coll. (Bristol, DESY, IPHC)
- Plume 01 prototype (<2012)</li>
  - Fabricated
    - 2 x 6 Mimosa 26 chips
    - 2 mm low density SiC foam
    - Validated in test beam (2011)
    - Operated with air cooling
    - > 0.6 % X₀
- Plume 02 prototype
  - Under construction (spring 2015)
  - Reduced mat. Budget
    - ➢ Reduced width (24.5 mm ⇒18mm)
    - Lighter (alu) flex cable, mechanical support
    - > 0.6 %  $X_0$  ⇒ ~ 0.35 %  $X_0$  (cross-section)





Width = 18 mm

### Next Forthcoming device: CBM Micro-Vertex Detector (MVD)



### **Device under Study: ILC Vertex Detector**



**ILD-VXD** at **ILC** 

3 double-sided layers

- $\sigma_{sp} \lesssim 3 \,\mu m$
- $\sim$  0.3 % X<sub>0</sub> / layer
- Radiation load: O(100) kRad +
   O(10<sup>11</sup>) n<sub>eq</sub>/cm<sup>2</sup> (1yr)



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### **BTF Telescope Simulation: Performances (I)**



## **BTF Telescope Simulation: Performances (II)**



## **BTF Analysis strategy & Efficiency correction**

### Analysis strategy

- Reconstruct tracks and extrapolate @ DUT
- Associate DUT hits to track within track-hit distance cut
- Evaluate DUT  $\epsilon_{det}$  and  $\sigma_{sp}$
- **Efficiency Correction:**  $\varepsilon_{det}^{corr} = (\varepsilon_{det}^{raw} p)/(1 p)$



- Due to MS non-Gaussian tails some track-hit distance seems quite large (few 100μm)
  - Enlarging the track-hit distance has 2 consequences on non-efficient events
    - Increases probability to get a fake hit in this area
    - → Increases probability to associate a real hit from other track
- Method
  - > Use efficient events to get the distribution of the 2<sup>nd</sup> closest hit to the track
  - Use normalized cumulated distribution to estimate p



## BTF Telescope Simulation: $\sigma_{Tel} @ 1^{st}$ DUT position



Telescope resolution @  $1^{st}$  DUT position (both DUTs supposed thinned to  $50\mu$ m)

$$σ_{_{Tel}}$$
 = (5.77 ± 0.01 $_{_{stat}}$  ± 0.20 $_{_{syst}}$ ) μm

Telescope resolution confirmed with Geant3 based simulation





### **CMOS Pixel Sensors: Established Architecture**

- Main characteristics of MIMOSA-26 sensor equipping EUDET BT :
  - $_{\rm 0}$  0.35  $\mu m$  process with high-resistivity epitaxial layer (coll. with IRFU/Saclay)
  - column // architecture with in-pixel amplification (cDS)
     and end-of-column discrimination, followed by Ø
  - binary charge encoding
  - active area: 1152 columns of 576 pixels  $(21.2 \times 10.6 \text{ mm}^2)$
  - $_{
    m o}\,$  pitch: 18.4  $\mu m 
    ightarrow \, \sim$  0.7 million pixels
    - hinspace charge sharing  $\Rightarrow$   $\sigma_{sp}$   $\sim$  3.-3.5  $\mu m$
  - $t_{r.o.} \lesssim 100 \ \mu s \ (\sim 10^4 \ \text{frames/s})$  $\hookrightarrow$  suited to  $> 10^6 \ \text{part./cm}^2/\text{s}$
  - JTAG programmable
  - rolling shutter architecture
    - $\Rightarrow$  full sensitive area dissipation  $\cong$  1 row
      - $ho~\sim$  250 mW/cm $^2$  power consumption (fct of N $_{col}$ )
  - $_{
    m o}~$  thinned to 50  $\mu m$  (yield  $\sim$  90 %)

Pixel array: 576 x 1152, pitch: 18.4 µm CMOS 0.35 µm OPTO technology Active area: -10.6 x 21.2 mm<sup>2</sup> Chip size : 13.7 x 21.5 mm<sup>2</sup> In each pixel: stability: several test point + Amplificatio nted all along readou > CDS (Correlated Double Sampli Pixels out (analogs Discriminators Zero suppression Data transmissio Width: ~350 µm 152 column-level discrimina offset compens gain prea by latch Zero suppression log Reference Voltages Buffering for 1152 **IO** Pads ower supply Pads Current Ref Memory ma Circuit control Pads Readout contr LVDS Tx & Rx Bias DACs JTAG controlle Memory IP blocks



Various applications: VD demonstrators, NA63, NA61, FIRST, oncotherapy, dosimetry, ...

# <sup>55</sup>Fe source: CCE/Noise/CNR vs diode for large pixels

CCE, TN and CNR vs sensing node for large pixels with HR18 epi-layer



- Good to excellent CCE, even for small sensing diodes or for  $33x66 \ \mu m^2$  pixels
- = TN ~ 17/11 e<sup>-</sup> ENC for single 10.9/8  $\mu$ m<sup>2</sup> sensing diodes
- TN ~ 17/15 e<sup>-</sup> ENC for pairs of 5/2  $\mu$ m<sup>2</sup> sensing diodes
- High CNR: up to ~60 for 8  $\mu$ m<sup>2</sup> sensing diodes
- Pixel detection performances fully satisfactory  $\Rightarrow$  confirmation from beam test (see next slide)

33\*66 um

22\*66 um

# <sup>55</sup>Fe source: CCE & Noise vs diode for small pixels

• CCE and TN for 22x33  $\mu$ m<sup>2</sup> pixels for different diode dimensions (footprint 10.9  $\mu$ m<sup>2</sup>)



- CCE is highest for HR18 epi-layer
- Weak dependence of CCE with diode dimensions  $\Rightarrow$  around 30% for  $2\mu m^2$
- Nearly linear variation of TN with diode dimensions  $\Rightarrow 8 \rightarrow 16 e^{-} ENC \text{ for diode } 2 \rightarrow 10.9 \ \mu\text{m}^{2}$
- Small sending diode with > 10  $\mu$ m<sup>2</sup> footprint attractive in terms of CCE

# <sup>55</sup>Fe source: radiation tolerance for 22x33 μm<sup>2</sup> pixels

- 22x33 μm<sup>2</sup> pixels with diode of 8 and 10.9 μm<sup>2</sup>: TN and CCE/CNR @ T = 30°C from <sup>55</sup>Fe source for different irradiations
- Comparison when possible of CNR and SNR from 4.4 GeV e<sup>-</sup> TB (DESY)
- Comments:
  - Small diode more sensitive to TID
  - TID impacts both CCE and TN
  - CNR of 10.9  $\mu$ m<sup>2</sup> diode pixel exceeds 20 (MPV) after 250 kRad + 2.5x10<sup>12</sup>n<sub>er</sub>/cm<sup>2</sup>



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# **MIMOSA-34: sensing node impact for small pixels**

### DESY BT Set-up (August 2013):

- 2BT: 8xSi-strips & 6xMIMOSA-26 (120 μm thick)
- ~4.4 GeV/c e<sup>-</sup> beam
- MIMOSA-34: 22x33 μm<sup>2</sup> pixels @ T = 30°C
  - Sensing node impact (HR18)
  - Sub-arrays: P-29 10.9/10.9 μm<sup>2</sup> diode/footprint
     P-20 8.0/10.9 μm<sup>2</sup> diode/footprint
  - $8\mu m^2$  diode features ~20% higher SNR (MPV)  $\Rightarrow$  slightly higher  $\epsilon_{det}$  (both > 99%)
  - $Q_{clus} \sim 1350/1500 e^{-}$  for  $8/10.9 \mu m^2$  diode  $\Rightarrow$  marginal charge loss
  - Binary residue: 5-5.5  $\mu$ m  $\Rightarrow \sigma_{sp} < 5 \mu$ m



# $\beta^{-}$ (<sup>90</sup>Sr) source vs 4.4 GeV e<sup>-</sup> (DESY)

- $\beta^-$  (<sup>90</sup>Sr) vs 4.4 GeV e<sup>-</sup> for 22x66  $\mu$ m<sup>2</sup> pixels: SNR &  $\epsilon_{det}$  for HR18/HR30
- Conclusion: lab test with  $\beta^-$  (<sup>90</sup>Sr) source allow estimating  $\epsilon_{det}$



# From 22x66 to 33x66 µm<sup>2</sup> pixels

- 22x66 vs 33x66  $\mu$ m<sup>2</sup> pixels: SNR &  $\epsilon_{det}$  with  $\beta^-$  (<sup>90</sup>Sr) for HR18/HR30
- Comment: 33x66  $\mu$ m<sup>2</sup> (8/15  $\mu$ m<sup>2</sup> diode/footprint) pixels exhibit high SNR  $\Rightarrow$  high  $\epsilon_{det}$



# 33x66 µm<sup>2</sup> pixels vs epitaxial-layer

- 33x66  $\mu$ m<sup>2</sup> pixels (8/15  $\mu$ m<sup>2</sup> diode/footprint): SNR &  $\epsilon_{det}$  with  $\beta^-$  (<sup>90</sup>Sr) for HR 18,20,30
- Comments:
  - Single 8/15 μm<sup>2</sup> diode/footprint provides high SNR despite large pixel (low sensing node density)
  - HR30 epi-layers gives high SNR (MPV ~ 70) from  $\beta^-$  (<sup>90</sup>Sr)  $\Rightarrow$  pretty high  $\epsilon_{det}$  for high SNR cut (e.g. 10)
  - Expected spatial resolution for 33x66  $\mu$ m<sup>2</sup> pixels:  $\sigma_{sn} \approx 10 \mu$ m





### Det. Efficiency & Fake rate

#### Measured from 128 columns ended with discriminators: MIMOSA-22THRa1





### MISTRAL-like: fake rate



Enlarged input transistor gate: Effective mitigation of fake rate due to noisy pixels

- STEPS VALIDATED IN 2012 :
  - \* Several in-pixel amplifier variants lead to satisfactory SNR & det. eff. ( $20 \times 20 \ \mu m^2$ ) incl. after 1 MRad &  $10^{13} n_{eq}$ /cm<sup>2</sup> at  $30^{\circ}$ C
  - \* Results pres. at VCI-2013 (J. Baudot)
- CALL FOR IMPROVEMENT :
  - \* Pixel circuitry noise :
    - tail due few noisy pixels
  - $\, \hookrightarrow \,$  attributed to RTS noise
  - $\Rightarrow$  required optimising T geometries









### **FSBB-M0bis main features**

har, 22 Januray 2015 416 columns

- TJsc-0.18 CIS process, HR (~1–2k $\Omega$ cm) 18/25/30 $\mu$ m epitaxy, thinned to 50 $\mu$ m
- Staggered pixel: 22x32.5 μm<sup>2</sup> including pre-amplification and clamping with 6 metal layers (ML)
- 416x416 = 173k of col. x row of pixels ended by discriminator (8-cols with analogue output)
- Double-row readout at 160MHz clock frequency  $\Rightarrow$  40µs integration time
- On-chip 3-stage sparsification: SUZE-02 (different from MISTRAL-0, SUZE-03)
- 4 Memories of 512x32 bits
- 2 output nodes at 320Mbits/s (used only one for TB)
- Integrated JTAG and regulators
- Sensitive area is 13.7 x 9.0 mm ~ 1.2cm<sup>2</sup>
- Improvements w.r.t FSBB-M0 ⇒ shortcomings solved
  - Mitigation of cross coupling effects
    - $\Rightarrow$  now capable of operating full matrix
  - Bit transmission: bit inversion at discriminator output
- Two sensing node variations in same chip
  - > (NMOS T<sub>input</sub> Pre-Amp W/L =  $1.5/0.28\mu$ m)
  - > Diode/Footprint: 8/16  $\mu m^2$
  - > Diode/Footprint: 9/13.3  $\mu m^2$





### Main FSBB-M0 Detection Performances (2/3)

- Study of detection efficiency stability :
  - \* Difference between SPS (120 GeV pions) & DESY (4.5 GeV electrons)
  - $_{*}\,$  Effect of occupancy : from  $\sim$  1 hit/frame to  $\sim$  25 hits/frame



 $\Rightarrow$  No variation observed

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## MIMOSA-22THRb6/7: characteristics

#### **Design features**

- 64x64 pixel array (staggered): 56 columns ended with discri. and 8 with analog output
- Readout  $\approx$  5µs (100MHz clock)
- Epitaxial layer: HR18

#### **Mi22-THRB6: 36×62.5µm<sup>2</sup>**



### Purpose of the chip

- Validate pads over pixels
- Validate in-pixel circuitry concentrated on  $\approx 3ML \Rightarrow$  modified clamping capacitor
- Validate large pixel performances w.r.t. TDR requirements on layers 3-6

⇒ MISTRAL-O

### **Reminder of lab results: Individual pixel response to <sup>55</sup>Fe X-rays**

- Mi22THRb7 has a gain quite uniform
- Mi22THRb6 shows gain dispersion among pixels  $\Rightarrow$  were not sure about the effect on  $\epsilon_{det}$



### Reminder of lab results: Temp. dependence of pixels to <sup>55</sup>Fe X-rays

- Mi22THRb7 has quite stable response vs T
- Mi22THRb6 shows a significant dependence with T:  $/T \Rightarrow /gain$




## Hot pixel masking effect on $\varepsilon_{det}$ & $\sigma_{sp}$ : Motivation

#### Reducing I pix

- Increases  $\epsilon_{det}$   $\Rightarrow$  dramatical effect for highly irradiated sensors
- Increases fake rate ⇒ factor of 10 increase for highly irradiated sensors
- Masking procedure can be a good strategy for highly irradiated sensors
  ⇒ can reduce fake rate by ~1 2 orders of magnitude depending masking fraction

### It is then important to study the effect of masking on $\varepsilon_{det}$ & $\sigma_{sp}$

- Masking will cut away some single pixel clusters
- $\varepsilon_{det}$  relative reduction should be prop. to (masking fraction) x (fraction mult. = 1 clusters)
  - > Should be a marginal effect due to sizeable pixel cluster multiplicity of FSBB
  - >  $\Delta \epsilon_{det}$  vs (fraction mult. = 1 clusters) should be linearly related
- $\sigma_{sp}$  should get marginally degraded due to loss of hit position information of masked pixels

#### Tested the above hypothesis on different sensors and varied configurations

- Non-irradiated sensors @ nominal configuration
- Highly irradiated sensor (1.6MRad +  $10^{13}n_{eq}$  (MeV)/cm<sup>2</sup>) for I<sub>pix</sub> = 30 & 50 (nominal)  $\mu$ A

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(::)

## Hot pixel masking effect on $\varepsilon_{det}$ & $\sigma_{sp}$ : Results (I)

Masking 0.00%

Masking 0.50%

Masking 1.00%

Masking 2.00%

7.5

8.5

9

Threshold / noise = TN

75



# Hot pixel masking effect on $\varepsilon_{det}$ & $\sigma_{sp}$ : Results (II)



# Motivation for depleted CPS



- High energy physics trend
  - Tolerate high non-ionizing part. Fluences 10<sup>15</sup> n<sub>eq</sub>/cm<sup>2</sup> (tracker / vertex)
  - Integration time ≪ µs
- X-rays detection
  - Require thickness (Beer-Lambert attenuation law)
  - Require equivalent collection properties all over epi-layer
- Fully depleting the sensitive layer is a key
  - However situation different / sensors for hybrid-systems (CERN-RD50)
    - ➡ Same substrate embed sensitive and first amplification layer



- Open questions
  - Which structure to enforce depletion?
    - Depth & uniformity on chip area
  - impact on in-pixel treatment µ-circuits?
    - Noise, transistor behavior

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# Way 1: High Voltage



#### Experiments

HV-CMOS

- ATLAS, µ2e, CLIC
- Groups in Bonn, CERN, Genève, Heidelberg, Karlsruhe, Marseille...

Deleted depth demonstrated

• new collab. → CERN-RD53

5 to 15 µm with 60-70V

Fast amplification ~ 1 µs

#### Concept

- Low resistivity (10-20 Ω.cm)
  - ➡ High Voltage applied few 10s V
- HV-compliant CMOS technologies



S.Feigl et al., PoS (TIPP2014) 280



- Depleted depth demonstrated 40-50 µm with 150-200 V
- Hint of tolerance beyond  $10^{14} n_{ea}/cm^2$

Only 30% signal loss after 10<sup>15</sup> n<sub>ea</sub>/cm<sup>2</sup>

! Prototypes area 10 mm<sup>2</sup>



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## Way 2: High Resistivity

- Experiments
  - ALICE, CBM
  - soft X-rays detection
  - Groups in Bonn, CERN, RAL, Strasbourg

- Concept
  - High Resistivity thin epi-layer
    - ➡ moderate voltage  $\lesssim$  10 V

See next slides for IPHC developments

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## **Depleted-CPS prototypes**



- 2 Technologies explored
- Tower Jazz 0.18 µm → Pegasus-1/2
  - Various sensitive layers
    - epi with >1 k $\Omega$ .cm, 18, 30, 40  $\mu$ m thick
    - Czochralski substrate-thick
  - Main architecture tested
    - Analogue readout with 10 µs integration time
    - Collection node AC-coupled to amplificator
  - Small matrix: 32 columns x 56 rows
  - Pixel size 25x25 µm<sup>2</sup>

#### EPC-ESPROSS 0.15 µm → MIMOSA-33

- high resistivity 50 µm thinned + passivated substrate
- Main architecture tested
  - Analogue read-out with 11 µs integration time
  - Back-side biasing through IP structure
- Small matrix: 8 columns x 44 rows
- Pixel size 25x25 µm<sup>2</sup>







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# Ongoing prototypes design

Submission to Tower-Jazz 0.18 µm technology (June 2015)

#### MIMOSA - 22 SX

- Forerunner of sensors dedicated to X-rays with energy < 5 keV
  - Pixel pitch  $\leq 25x25 \,\mu\text{m}^2$  and  $\approx 10^4$  photons/pixel/sec
- Developed with the detector group of SOLEIL ٠
- "Not so small" matrix: 5.6x 4.4 mm<sup>2</sup>
- combine :
  - AC coupled collection diode from PEGASUS
  - read-out architecture developed for ALICE
- Binary output:
  - From 2 discriminators/column → energy window selection
  - Photons detected individually  $\rightarrow$  counting & spatial resolution
- <u>Small analogue prototype</u>

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- Faster amplification  $\rightarrow$  target 10<sup>6</sup> photons/pixel/sec
- Mitigation of noise





## ILD - VXD Concept Addressed

- Two types of CMOS Pixel Sensors :
  - Inner layers : Priority to read-out speed & spatial resolution
  - Outer layers : Priority to power consumption and good resolution
- Inner layers :  $\sim$  300 cm $^2$ 
  - L1 : small pixels with end-of-column
    - binary charge encoding  $\mapsto \ \lesssim$  3  $\mu m$
    - $_{pprox}$  20imes14  $\mu m^2$  with 2-row read-out :  $\lesssim$  40  $\mu s$
    - $\approx$  17imes17  $\mu m^2$  with 1-row read-out : 60  $\mu s$ 
      - $\hookrightarrow$  2-row read-out : 30  $\mu s$  (tbc)
  - $\,\circ\,$  L2 : elongated pixels with in-pixel binary charge encoding  $\mapsto\,\sim$  5  $\mu m$ 
    - $_{pprox}$  22imes33  $\mu m^2$  with 2-row read-out :  $\sim$  8  $\mu s$
    - $_{pprox}$  22imes33  $\mu m^2$  with 4-row (tbc) read-out :  $\sim$  4  $\mu s$
- Outer layers :  $\sim$  3000 cm $^2$ 
  - L3-6 : large pixels with end-of-col 3-4 bit ADCs
    - $\circ~$  35imes35  $\mu m^2$  pixels :  $\lesssim$  4  $\mu m$  & 120  $\mu s$
    - $_\circ~$  25imes50  $\mu m^2$  pixels :  $\lesssim$  4  $\mu m$  & 80  $\mu s$



## **Processes Suited to the R&D**

- Specific aspects of Tower 0.18  $\mu m$  CIS process : established contact
  - access to various starting materials (incl. in MPW)
  - designing details well known by the designers and testing crews
- COMPARISON TO L-FOUNDRY (INFO. TBC) : used by HL-LHC R&D groups

Process	Feature Size	Supply Voltage	Number of ML	Туре	Comments
Tower-SC	180 nm	1.8 V (3.3 V)	6	4-well	
L-Foundry	150 nm	1.8 V (3.3 V)	8	4-well	110 nm : 1.2 V

Process	MPW runs min. area cost duration		MLM runs area cost		
Tower-SC	$5$ x5 mm $^2$	37,500 USD	$\gtrsim$ 4.5 months	none	
L-Foundry	???	???	???	$11x11 \text{ mm}^2$	60-80 kE

Process	Starting Material				Comments
	thickness	resistivity	source	availability	
Tower-SC	18-40 $\mu m$ or more	$\sim$ 1 - 10 k $\Omega \cdot cm$	internal & external	MPW, ER	
L-Foundry	??	High-Res	internal only ?	MLM, ER	

## **PXL in STAR Inner Detector Upgrades**



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## **CPS State-of-the-Art in operation: STAR-PXL detector**







#### **STAR-PXL HALF-BARREL**

- 2 layers @ r = 2.8,8 cm
- 20 ladders (10 sensors) (0.37% X<sub>0</sub>)
  - $\rightarrow$  200 sensors  $\Rightarrow$  180x10<sup>6</sup> pixels
- Air flow cooling: T < 35°C



Several Physics-runs  $1^{st}$  run Mar-Jun 2014  $2^{nd}$  run Jan-Jun 2015 Measured  $\sigma_{ip}(p_T)$  matching requirements (~40 µm @ 600 MeV/c for  $\pi^{\pm}/K^{\pm}$ )

Getting prepared for 3<sup>rd</sup> run (Jan. 2016)

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## Main FSBB-M0 detection performances (2/3)

#### Spatial resolution vs cluster pixel size



- Charge sharing depends on track impinging position w.r.t coll. diode
- Spatial resolution is mostly dependent on # pixels/cluster
- $\sigma_{sp}$ (Mult=1) ~ 4.2  $\mu$ m <  $\sigma_{sp}^{digi}$  ~ 7.8  $\mu$ m

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## Main MIMOSA-22THRb detection performances (1/2)

Pixel type	Pixel dim.	Diode/Footprint	Pre-Amp T.	Clamping capa.	Integ. time
MIMOSA-22THRb7	39 $\mu m$ x 50.8 $\mu m$	5/16 $\mu m^2$	N-MOS	MOS (N-well)	5 $\mu s$
MIMOSA-22THRb6	36 $\mu m$ x 62.5 $\mu m$	7/16 $\mu m^2$	P-MOS	fringe (metal layers)	5 $\mu s$



- Excellent detection performances for both chip variations
  - $\epsilon_{det}$  > 99% &  $\sigma_{sp}$  ~ 10 µm (as expected)
- P-MOS vs N-MOS Pre-Amply input transistor
  - **P-MOS:** less RTS noise, higher gain and sensing node voltage
  - **N-MOS:** better pixel response uniformity, less T-dependency and maturity (STAR-PXL)

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U residue

V residue Fake rate

<# Suze Windows>

## Main MIMOSA-22THRb detection performances (2/2)

- Study of rad. tolerance @ T ≥ 30 °C: loads relevant to ALICE-ITS outer layers
  - Load: up to 150 kRad ⊕ 1.5×10<sup>12</sup>n /cm<sup>2</sup>



### MIMOSA-22THRb7 (N-MOS Pre-Amp input transistor)



- Good detection performances after irradiation
- Validation of large pixel design for the outer layers of the ALICE-ITS!

## **Forthcoming Challenges**

How to reach the right bottom corner of the "Quadrature"?

